

P17529.A12



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants : Hwee Hwa PANG et al.

Group Art Unit: 2191

Appln. No. : 09/856,513

Examiner: Satish RAMPURIA

Filed : June 15, 2001

Confirmation No.: 5665

For : PROCESS ORIENTED COMPUTING ENVIRONMENT

**RESPONSE UNDER 37 C.F.R. § 1.116**

Commissioner for Patents  
U.S. Patent and Trademark Office  
Customer Service Window, Mail Stop Amendment  
Randolph Building  
401 Dulany Street  
Alexandria VA 22314

Sir:

In response to the Final Official Action of April 21, 2005, in which a three-month shortened statutory period for response has been extended from July 21, 2005 to expire on September 21, 2005 by a request and payment for a two-month extension of time, Applicants respectfully request reconsideration and withdrawal of the outstanding rejections set forth in the above-mentioned Final Official Action in view of the herein contained amendments and remarks.

**Amendments to the Specification** begin on page 2 of this Response.

**Amendments to the Claims** begin on page 3 of this Response.

**Remarks** begin on page 12 of this Response.

*Entered ref  
RCE dtd 10/26/05  
EOWme 11-2-05*